IAP12 Rec'd PCT/FTO 05 MAY 2006

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Syo-ichi TAKAMIZAWA et al.

Application No.: New U.S. National Stage of PCT/JP2004/012179

Filed: May 5, 2006 Docket No.: 127101

For: METHOD FOR PRODUCING SILICON EPITAXIAL WAFER

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Pursuant to 37 CFR §1.56, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached PTO-1449. Unless otherwise indicated herein, one copy of each reference is attached. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

- 1. This Information Disclosure Statement is being filed (a) within three months of the U.S. filing date of this non-CPA application, OR (b) before the mailing date of a first Office Action on the merits in the present application. No certification or fee is required.
- 2. Relevance of one or more non-English language reference is discussed in the present specification. See References 6 and 7.
- 3. One or more reference cited herein was cited in the International Search Report. An English language version of the International Search Report is attached for the Examiner's information. See References 3-5 and 7.
- 4. In accordance with 37 CFR §1.98(a)(2)(ii), copies of any U.S. patents and patent application publications are not attached.
- 5. An English language Abstract of one or more non-English language reference is attached hereto. See References 3-7.
- 6. A computer-generated English language translation of one or more Japanese Patent Publication cited herein has been obtained from the website of the Japanese Patent Office ([http://www.jpo.go.jp]), and is attached, but has not been reviewed for accuracy. See References 3, 5 and 7.

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 \boxtimes 7. Reference $\underline{1}$ corresponds to reference $\underline{4}$. Reference $\underline{2}$ corresponds to reference 5.

Respectfully submitted,

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WPB:JOC/per

Date: May 5, 2006

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Sheet 1 of 1

Form PTO-1449 US Dept. of Co (REV. 1/06) PATENT & TRADEMARK INFORMATION DISCLOSURE STATEMENT				ATTY DOCKET NO. 127101			APPLICATION NO. New U.S. National Stage of PCT/JP2004/012179	
	e several sheets if necessary)		APPLIC Syo-ichi	CANTS i TAKAMIZAWA et al.				
			FILING May 5,					
		U.	.S. PATEN	Γ DOCUM	MENTS			
Examiner Initials	Cite No.	Document Number	Date		Name			
	1.	4,662,956	5/5/1987		Roth et al.			
	2.	6,013,564	1/11/2000		Muramatsu			
FOREIGN PATENT DOCUMENTS								
Examiner Initials	Cite No.	Document Number	Da	te	Country		With English Abstract	With English Translation
	3.	JP A 11-100299	4/13/1999		JAPAN		x	x
	4	JP A 62-502438	9/17/1987		JAPAN		х	
	5.	JP A 10-106955	4/24/1998		JAPAN		х	х
	6.	JP A 58-41799	3/11/1983		JAPAN		х	
	7.	JP A 9-120947	5/6/1997		JAPAN		х	х
OTHER DOCUMENTS								
Examiner Initials	Cite No.	(Including Author, Title, Date, Pertinent Pages, etc.)						
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EXAMINER	DATE CONSIDERED							
Examiner:	Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							

Date: May 5, 2006